

Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS

Laboratory and Research

Course Overview

Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS: a 5-day professional training course from LTC Consultants, delivered in-classroom across Africa...

What You Will Achieve

- Explain the core principles and current good practice in Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS
- Apply practical tools and techniques for Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS in your own organisation
- Analyse real-world scenarios and select the right approach with confidence
- Avoid the common pitfalls that undermine Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS in practice
- Build a personal action plan to implement what you have learned

Who Should Attend

Professionals, specialists and managers at every level who want to strengthen this capability and apply it with confidence at work.

Course Outline

1. Foundations of Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS: principles, terminology and context
2. The business case: why Inductively Coupled Plasma Techniques: ICP-AES and ICP-MS matters to performance
3. Core tools, frameworks and methods
4. Applying the tools: guided case study and exercises
5. Common pitfalls and how experienced practitioners avoid them
6. Working with stakeholders: communication and influence
7. Measuring results and continuous improvement
8. Personal action planning and course review

Upcoming Dates and Fees

DATES	VENUE	FEE (PER DELEGATE)
19 to 23 Oct 2026	Windhoek	\$1,650
26 to 30 Oct 2026	Dar es Salaam	\$1,650
2 to 6 Nov 2026	Online	\$750

16 to 20 Nov 2026	Pretoria	\$1,650
23 to 27 Nov 2026	Gaborone	\$1,550
30 Nov to 4 Dec 2026	Kigali	\$1,395
7 to 11 Dec 2026	Cape Town	\$1,650

LTC Consultants

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Every delegate receives a Certificate of Attendance. Group and in-house rates available on request.